

Solids and Semi-conductor 1

# Semi-conductor Devices

#### **Energy Bands**

In isolated atom the valence electrons can exist only in one of the allowed orbitals each of a sharply defined energy called energy levels. But when two atoms are brought nearer to each other, there are alterations in energy levels and they spread in the form of bands.

Energy bands are of following types

# (1) Valence band

The energy band formed by a series of energy levels containing valence electrons is known as valence band. At o *K*, the electrons fills the energy levels in valence band starting from lowest one.

(i) This band is always fulfill by electron.

(ii) This is the band of maximum energy.

(iii) Electrons are not capable of gaining energy from external electric field.

(iv) No flow of current due to such electrons.

(v) The highest energy level which can be occupied by an electron in valence band at 0 K is called fermi level.

# (2) Conduction band

The higher energy level band is called the conduction band.

(i) It is also called empty band of minimum energy.

(ii) This band is partially filled by the electrons.

(iii) In this band the electrons can gain energy from external electric field.

(iv) The electrons in the conduction band are called the free electrons. They are able to move any where within the volume of the solid.

(v) Current flows due to such electrons.

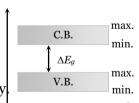
# (3) Forbidden energy gap ( $\Delta E_g$ )

Energy gap between conduction band and valence band  $\Delta E_g = (C.B.)_{min} - (V.B.)_{max}$ 

(i) No free electron present in forbidden energy gap.

(ii) Width of forbidden energy gap upon the nature of substance.

(iii) As temperature increases ( $\uparrow$ ), forbidden energy gap decreases ( $\downarrow$ ) very slightly



# **Types of Solids**

On the basis of band structure of crystals, solids are divided in three categories.

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S.No.	Properties	Conductors	Insulators	Semiconductors	
(1)	Electrical conductivity	10 <sup>2</sup> to 10 <sup>8</sup> $\mho/m$	10 <sup>-8</sup> Ŭ/m	10 <sup>-5</sup> to 10° ℧/m	
(2)	Resistivity	10 <sup>-2</sup> to 10 <sup>-8</sup> Ω-m (negligible)	10 <sup>8</sup> Ω-m	10 <sup>5</sup> to 10º Ω-m	
(3)	Band structure	C.B. V.B.	C.B. $\Delta E_q$ (maximum) V.B.	C.B. $\Delta E_g$ (less) V.B.	
(4)	Energy gap	Zero or very small	Very large; for diamond it is 6 <i>eV</i>	For $Ge E_g = 0.7 \ eV$ for $Si E_g = 1.1 \ eV$	
(5)	Current carries	Free electrons		Free electrons and holes	
(6)	Condition of V.B. and C.B. at ordinary temperature	V.B. and C.B. are completely filled or C.B. is some what empty	V.B. – completely filled C.B. – completely unfilled	V.B. – somewhat empty C.B. – somewhat filled	
(7)	Temperature co-efficient of resistance ( $\alpha$ )	Positive	Zero	Negative	
(8)	Effect of temperature on conductivity	Decreases	_	Increases	
(9)	Effect of temperature on resistance	Increases	_	Decreases	
(11)	Examples	<i>Cu</i> , <i>Ag</i> , <i>Au</i> , <i>Na</i> , <i>Pt</i> , <i>Hg</i> etc.	Wood, plastic, mica, diamond, glass etc.	Ge, Si, Ga, As etc.	
(12)	Electron density	$10^{29}/m^3$	_	$Ge \sim 10^{19} / m^3$ $Si \sim 10^{16} / m^3$	

#### Holes in semiconductors

At absolute zero temperature (O *K*) conduction band of semiconductor is completely empty and the semiconductor behaves as an insulator.

When temperature increases the valence electrons acquires thermal energy to jump to the conduction band (Due to the braking of covalent bond). If they jumps to C.B. they leaves behind the deficiency of electrons in the valence band. This deficiency of electron is known as *hole* or cotter. A hole is considered as a seat of positive charge, having magnitude of charge equal to that of an electron.

- (1) Holes acts as virtual charge, although there is no physical charge on it.
- (2) Effective mass of hole is more than electron.
- (3) Mobility of hole is less than electron.

# **Types of Semiconductors**

# (1) Intrinsic semiconductor

A pure semiconductor is called intrinsic semiconductor. It has thermally generated current carriers (i) They have four electrons in the outermost orbit of atom and atoms are held together by covalent bond

(ii) Free electrons and holes both are charge carriers and  $n_e$  (in C.B.) =  $n_h$  (in V.B.)

(iii) The drift velocity of electrons  $(v_e)$  is greater than that of holes  $(v_h)$ 

(iv) For them fermi energy level lies at the centre of the C.B. and V.B.

(v) In pure semiconductor, impurity must be less than 1 in 10<sup>8</sup> parts of semiconductor.

(vi) In intrinsic semiconductor  $n_e^{(o)} = n_h^{(o)} = n_i = AT^{3/2}e^{-\Delta E_g/2KT}$ ; where  $n_e^{(o)} =$  Electron density in conduction band,  $n_h^{(o)} =$  Hole density in V.B.,  $n_i =$  Density of intrinsic carriers.

(vii) Because of less number of charge carriers at room temperature, intrinsic semiconductors have low conductivity so they have no practical use.

# Net current and conductivity

When some potential difference is applied across a piece of intrinsic semiconductor current flows in it due to both electron and holes *i.e.*  $i = i_e + i_h \Rightarrow i = n_e eAv_e$   $i = eA[n_ev_e + n_hv_h]$ 

Hence conductivity of semiconductor  $\sigma = e[n_e \mu_e + n_h \mu_h]$ 

where  $v_e$  = drift velocity of electron,  $v_h$  = drift velocity of holes,

*E* = Applied electric field 
$$\mu_e = \frac{v_e}{E}$$
 = mobility of  $e^-$  and  $\mu_n = \frac{v_h}{E}$  = mobility of hole

Note: 
$$\Box$$
  $(ni)_{Ge} \approx 2.4 \times 10^{19} / m^3$  and  $(ni)_{Si} \approx 1.5 \times 10^{16} / m^3$ 

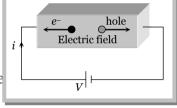
- $\Box$  At room temperature  $\sigma_{Ge} > \sigma_{Si}$
- $\Box \quad \mu_e > \mu_h$
- □ Conductivity of semiconductor increases with temperature because number density of charge carriers increases.
- □ In a doped semiconductor, the number density of electrons and holes is not equal. But it can be established that  $n_e n_h = n_i^2$ ; where  $n_e$ ,  $n_h$  are the number density of electrons and holes respectively and  $n_i$  is the number density of intrinsic curries (*i.e.* electrons or holes) in a pure semiconductor. This product is independent of donor and acceptor impurity doping.

# (2) Extrinsic semiconductor

- (i) It is also called impure semiconductor.
- (ii) The process of adding impurity is called Doping.
- (iii) Impurities are of two types :

Pentavalent impurity	<b>Trivalent impurity</b>
impurities e.g. As, P, Sb etc. These are also called	The elements whose each atom has three valance electrons are called trivalent impurities e.g. In, Ga, Al, B, etc. These impurities are also called acceptor impurities as they accept electron.

(iv) The number of atoms of impurity element is about 1 in 10  $^8$  atoms of the semiconductor. (v)  $n_e \neq n_h$ 



Impurity

Extrinsic

semiconductor

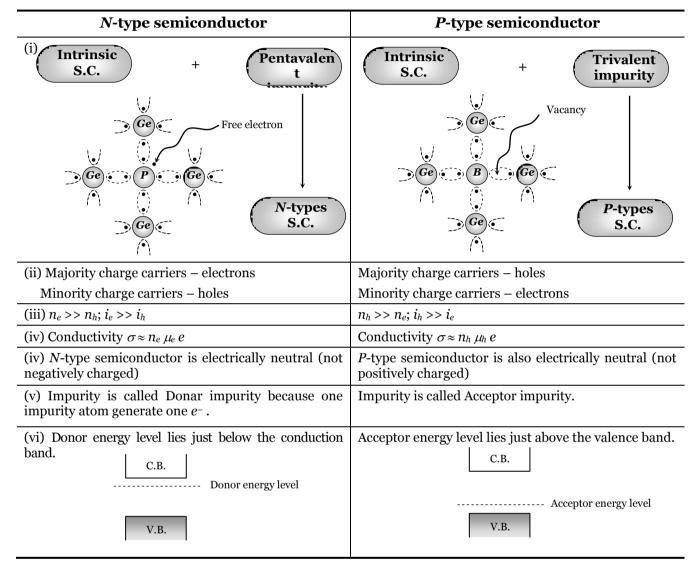
Intrinsic semiconductor

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(vi) In these fermi level shifts towards valence or conduction energy bands.

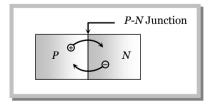
(vii) Their conductivity is high and they are practically used.

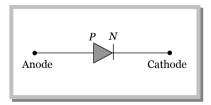
# (3) Types of extrinsic semiconductor



# **P-N** Junction Diode

When a P-type semiconductor is suitably joined to an N-type semiconductor, then resulting arrangement is called P-N junction or P-N junction diode





# (1) **Depletion region**

On account of difference in concentration of charge carrier in the two sections of *P*-*N* junction, the electrons from *N*-region diffuse through the junction into *P*-region and the hole from *P* region diffuse into *N*-region.

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Due to diffusion, neutrality of both N and P-type semiconductor is disturbed, a layer of negative charged ions appear near the junction in the P-crystal and a layer of positive ions appears near the junction in N-crystal. This layer is called depletion layer

(i) The thickness of depletion layer is 1 *micron* =  $10^{-6}$  *m*.

(ii) Width of depletion layer  $\propto \frac{1}{\text{Dopping}}$ 

(iii) Depletion is directly proportional to temperature.

(iv) The *P-N* junction diode is equivalent to capacitor in which the depletion layer acts as a dielectric.

# (2) Potential barrier

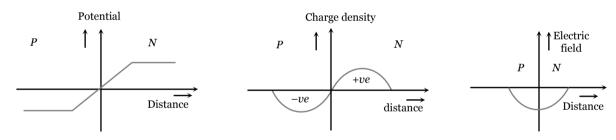
The potential difference created across the *P-N* junction due to the diffusion of electron and holes is called potential barrier.

For  $Ge = V_B = 0.3V$  and for silicon  $V_B = 0.7V$ 

On the average the potential barrier in *P-N* junction is ~ 0.5 V and the width of depletion region ~  $10^{-6}$ .

So the barrier electric field  $E = \frac{V}{d} = \frac{0.5}{10^{-6}} = 5 \times 10^5 V/m$ 

## Some important graphs



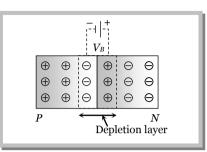
# (3) Diffusion and drift current

Because of concentration difference holes/electron try to diffuse from their side to other side. Only these holes/electrons crosses the junction, having high kinetic energy. This diffusion results is an electric current from the *P*-side to the *N*-side known as diffusion current ( $i_{df}$ )

As electron hole pair (because of thermal collisions) are continuously created in the depletion region. These is a regular flow of electrons towards the *N*-side and of holes towards the *P*-side. This makes a current from the *N*-side to the *P*-side. This current is called the drift current ( $i_{dr}$ ).

**Note** :  $\Box$  In steady state  $i_{df} = i_{dr}$  so  $i_{net} = 0$ 

□ When no external source is connected, diode is called unbiased.



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## (4) Biasing

Means the way of connecting emf source to P-N junction diode

Forward biasing	Reverse biasing	
(i) Positive terminal of the battery is connected to the <i>P</i> -crystal and negative terminal of the battery is connected to <i>N</i> -crystal $\xrightarrow{-1}_{E} E$	(i) Positive terminal of the battery is connected to the <i>N</i> -crystal and negative terminal of the battery is connected to <i>P</i> -crystal $\xrightarrow{E} E$ $\xrightarrow{e} \oplus \oplus$	
(ii) Width of depletion layer decreases (iii) $R_{\text{Forward}} \approx 10\Omega - 25\Omega$	(ii) Width of depletion layer increases (iii) $R_{\text{Reverse}} \approx 10^5 \Omega$	
(iv) Forward bias opposes the potential barrier and for $V > V_B$ a forward current is set up across the junction.	<ul><li>(iv) Reverse bias supports the potential barrier and no current flows across the junction due to the diffusion of the majority carriers.</li><li>(A very small reverse currents may exist in the circuit due to the drifting of minority carriers across the junction)</li></ul>	
(v) Cut-in (Knee) voltage : The voltage at which the current starts to increase. For <i>Ge</i> it is 0.3 <i>V</i> and for <i>Si</i> it is 0.7 <i>V</i> .	(v) Break down voltage : Reverse voltage at which break down of semiconductor occurs. For <i>Ge</i> it is 25 $V$ and for <i>Si</i> it is 35 $V$ .	
(vi) $df - diffusion$ dr - drift P N dr - drift $I_{df}$ $I_{dr}$ $I_{$	(vi) $\leftarrow$ Reverse voltage Break down voltage $\downarrow$ $\downarrow$ $\downarrow$ $\downarrow$ $\downarrow$ $\downarrow$ $\downarrow$ $\downarrow$	

# **Reverse Breakdown and Special Purpose Diodes**

#### (1) Zener breakdown

When reverse bias is increased the electric field at the junction also increases. At some stage the electric field becomes so high that it breaks the covalent bonds creating electron, hole pairs. Thus a large number of carriers are generated. This causes a large current to flow. This mechanism is known as **Zener breakdown**.

# (2) Avalanche breakdown

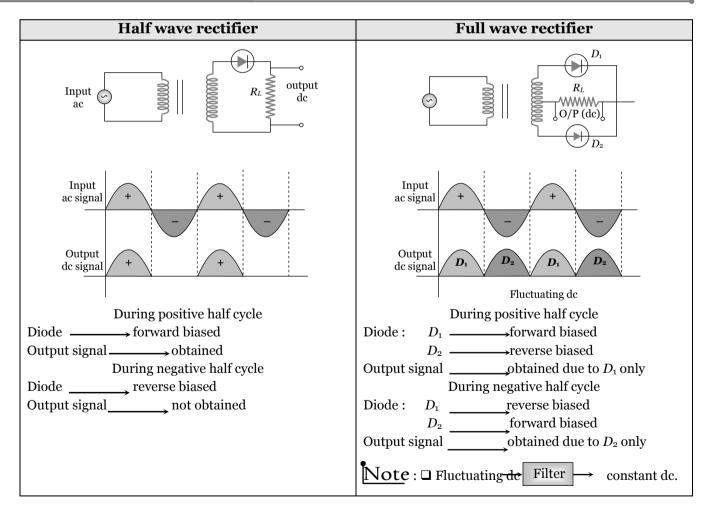
At high reverse voltage, due to high electric field, the miniority charge carriers, while crossing the junction acquires very high velocities. These by collision breaks down the covalent bonds, generating more carriers. A chain reaction is established, giving rise to high current. This mechanism is called **avalanche breakdown**.

# (3) Special purpose diodes

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Zener diode	Light emitting diode (LED)	Photo diode	Solar cells
It is a highly doped <i>p-n</i> junction which is not damaged by high reverse current. The breakdown	Specially designed diodes,	In these diodes electron and hole pairs are created by junction photoelectric effect. That is the	It is based on the photovoltaic effect. One of the semiconductor region is made so thin that the light incident on it reaches the <i>p</i> - <i>n</i> junction and gets
voltage is made very sharp. In the forward bias, the zener diode acts as ordinary diode. It can be used as voltage regulator	GaAsp, Gap etc.	covalent bonds are broken by the EM radiations absorbed by the electron in the V.B. These are used for detecting light signals.	absorbed. It converts solar energy into electrical energy.

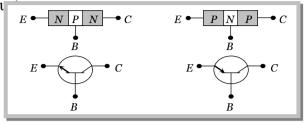
## *P-N* Junction Diode as a Rectifier



#### Transistor

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A junction transistor is formed by sandwiching a thin layer of *P*-type semiconductor between two *N*-type semiconductors or by sandwiching a thin layer of *n*-type semiconductor between two *P*-type semiconductor between two *P*-type



*E* – Emitter (emits majority charge carriers)
 *C* – Collects majority charge carriers
 *B* – Base (provide proper interaction between E and *C*)

**Note**: In normal operation base-emitter is forward biased and collector base junction is reverse biased.

(1) **Working of Transistor :** In both transistor emitter - base junction is forward biased and collector – base junction is reverse biased.

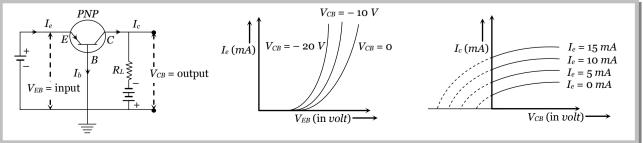
NPN – transistor	PNP – transistor
$ \begin{array}{cccccccccccccccccccccccccccccccccccc$	$N P N$ $I_{e} \bigoplus \bigoplus$
$I_{e}$ $I_{b}$ $I_{b}$ $V_{EB}$ $V_{CB}$	$I_{e}$ $I_{c}$ $I_{b}$ $I_{b}$ $V_{EB}$ $V_{CB}$
5% emitter electron combine with the holes in the base region resulting in small base current. Remaining 95% electrons enter the collector region.	5% emitter holes combine with the electrons in the base region resulting in small base current. Remaining 95% holes enter the collector region.
$I_e > I_c$ , and $I_c = I_b + I_c$	$I_e > I_c$ , and $I_c = I_b + I_c$

Note : 

 In a transistor circuit the reverse bias is high as compared to the forward bias. So that it may exert a large attractive force on the charge carriers to enter the collector region.
 (2) Characteristics of transistors : A transistor can be connected in a circuit in the following

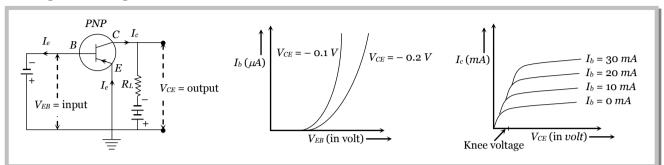
(2) **Characteristics of transistors :** A transistor can be connected in a circuit in the following three different configurations.

(i) Common base (CB)
(ii) Common emitter (CE)
(iii) Common collector (CC)
(i) CB characteristics : The graphs between voltages and currents when base of a transistor is common to input and output circuits are known as CB characteristic of a transistor.

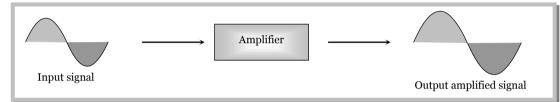


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(ii) CE characteristics : The graphs between voltages and currents when emitter of a transistor is common to input and output circuits are known as CE characteristics of a transistor.



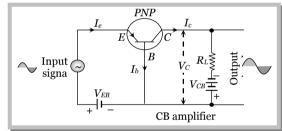
(3) **Transistor as an amplifier :** A device which increases the amplitude of the input signal is called amplifier.

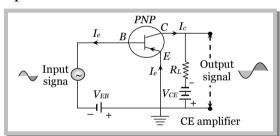


The transistor can be used as an amplifier in the following three configuration

(i) CB amplifier (i

(ii) CE amplifier (iii) CC amplifier





(4) Parameters of CE/CB amplifiers

Transistor as C.E. amplifier	Transistor as C.B. amplifier	
(i) Current gain ( $\alpha$ )	(i) Current gain ( $\beta$ )	
(a) $\alpha_{ac} = \frac{\text{Small change in collector current } (\Delta i_c)}{\text{Small change in collector current } (\Delta i_e)};$	(a) $\beta_{ac} = \left(\frac{\Delta i_c}{\Delta i_b}\right)  V_{CE} = \text{constant}$	
$V_B$ (constant)		
(b) $\alpha_{dc}(\text{or}\alpha) = \frac{\text{Collector current}(i_c)}{\text{Emitter current}(i_e)}$	(b) $\beta_{dc} = \frac{i_c}{i_b}$	
value of $\alpha_{dc}$ lies between 0.95 to 0.99	value of $\beta_{ac}$ lies between 15 and 20	
(ii) Voltage gain	(ii) Voltage gain	
$A_{v} = \frac{\text{Change in output voltage}(\Delta V_{o})}{\text{Change in input voltage}(\Delta V_{i})}$	$A_v = \frac{\Delta V_o}{\Delta V_i} = \beta_{ac} \times \text{Resistance gain}$	
$\Rightarrow A_v = \alpha_{ac} \times \text{Resistance gain}$		
(iii) Power gain = $\frac{\text{Change in output power}(\Delta P_o)}{\text{Change in input power}(\Delta P_c)}$	(iii) Power gain = $\frac{\Delta P_o}{\Delta P_i} = \beta_{ac}^2 \times \text{Resistance gain}$	
$\Rightarrow$ Power gain = $\alpha_{ac}^2 \times$ Resistance gain	•	

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**Note** :  $\Box$  **Trans conductance (gm)** : The ratio of the change in collector current to the change in emitter base voltage is called trans conductance. *i.e.*  $g_m = \frac{\Delta i_c}{\Delta V_{EB}}$ . Also  $g_m = \frac{A_V}{R_L}$ ;  $R_L =$  Load resistance

(5) **Relation between** 
$$\alpha$$
 and  $\beta$ :  $\beta = \frac{\alpha}{1-\alpha}$  or  $\alpha = \frac{\beta}{1+\beta}$ 

# (6) Comparison between CB, CE and CC amplifier

S.No.	Characteristic	Amplifier		
		CB	CE	CC
(i)	Input resistance $(R_i)$	$\approx$ 50 to 200 $\Omega$ low	≈ 1 to 2 $k\Omega$ medium	≈ 150 – 800 $k\Omega$ high
(ii)	Output resistance $(R_o)$	≈ 1 – 2 $k\Omega$ high	≈ 50 $k\Omega$ medium	$\approx k\Omega$ low
(iii)	Current gain	0.8 – 0.9 low	20 – 200 high	20 – 200 high
(iv)	Voltage gain	Medium	High	Low
(v)	Power gain	Medium	High	Low
(vi)	Phase difference between input and output voltages	Zero	180°	Zero
(vii)	Used as amplifier for	current	Power	Voltage

#### Example

Example: 2	-	loped with <i>Al</i> . The concentration of electron hole pairs is	-	
	(a) $10^{17} / m^3$	(b) $10^{15} / m^3$	(c) $10^4 / m^3$	(d) $10^2 / m^3$
Solution : (a)	$n_i^2 = n_h n_e \implies (10^2)$	$(9)^{2} = 10^{21} \times n_{e} \implies n_{e} = 10^{17} / n_{e}$	$n^3$ .	
Example: 3	A silicon specimen is made into a <i>P</i> -type semi-conductor by doping, on an average, one Indium atom per $5 \times 10^7$ silicon atoms. If the number density of atoms in the silicon specimen is $5 \times 10^{28}$ atoms/m <sup>3</sup> , then the number of acceptor atoms in silicon will be			
Solution : (c)		$s/cm^3$ (b) $1.0 \times 10^{13}$ atoms/cm atoms in silicon specimen = 5 >		,
	Since one atom of indium is doped in $5 \times 10^7$ <i>Si</i> atom. So number of indium atoms doped per <i>cm</i> <sup>-3</sup> of silicon.			
	$n = \frac{5 \times 10^{22}}{5 \times 10^7} = 1 \times$	$10^{15} atom / cm^3$ .		
Example: 4	A <i>P</i> -type semiconductor has acceptor levels 57 <i>meV</i> above the valence band. The maximum wavelength of light required to create a hole is (Planck's constant $h = 6.6 \times 10^{-34} J$ -s)			
	(a) 57 <i>Å</i>	<b>(b)</b> $57 \times 10^{-3} \text{ Å}$	(c) 217100 $Å$	(d) $11.61 \times 10^{-33} \text{ Å}$
Solution : (c)	$E = \frac{hc}{\lambda} \implies \lambda = \frac{hc}{E} = \frac{6.6 \times 10^{-34} \times 3 \times 10^8}{57 \times 10^{-3} \times 1.6 \times 10^{-19}} = 217100 \text{ Å}.$			
Example: 5	-	of 0.50 <i>V</i> exists across a <i>P-N</i> ju electric field in this region is	nction. If the depletion re	egion is $5.0 \times 10^{-7} m$ wide, [UPSEAT 2002]
	(a) $1.0 \times 10^6 V/m$	(b) $1.0 \times 10^5 V/m$	(c) $2.0 \times 10^5 V/m$	(d) $2.0 \times 10^6 V/m$

Solution : (a)	$E = \frac{V}{d} = \frac{0.50}{5 \times 10^{-7}} = 1 \times 10^6  V/m.$					
Example: 6	<b>Example: 6</b> A 2V battery is connected across the points A and B as shown in the figure given below.					
1	that the resistance of each diode is zero in forward					
	supplied by the battery when its positive terminal is c	onnected to A is				
	(a) 0.2 <i>A</i>					
	(b) $0.4A$	10 0				
	(c) Zero					
	(d) 0.1 <i>A</i>					
Solution : (a)		Since diode in upper branch is forward biased and in lower branch is reversed biased. So current				
	through circuit $i = \frac{V}{R + r_d}$ ; here $r_d$ = diode resistance	in forward biasing = 0				
	So $i = \frac{V}{R} = \frac{2}{10} = 0.2A$ .					
Example: 7	Current in the circuit will be					
	(a) $\frac{5}{40}A$					
	(a) $\frac{1}{40}$ A					
	(b) $\frac{5}{50}A$	30				
	(b) $\frac{1}{50}$ A					
	(-) 5 (	i •				
	(c) $\frac{5}{10}A$					
	(d) $\frac{5}{20}A$	20 31				
	20					
<i>Solution</i> : (b)	The diode in lower branch is forward biased and diod	e in upper branch is reverse blased				
	$\therefore  i = \frac{5}{20 + 30} = \frac{5}{50}A$					
	201 30 30					
Example: 8	Find the magnitude of current in the following circuit	[RPMT 2001]				
	(a) o					
	(b) 1 <i>amp</i>					
	(c) 0.1 <i>amp</i>					
	(d) 0.2 <i>amp</i>					
Solution : (a)	Diode is reverse biased. Therefore no current will flow	v through the circuit.				
Example: 9	The diode used in the circuit shown in the figure has	0				
	and a maximum power rating of 100 milliwatts.	What should be the value of the resistor $R$ ,				
	connected in series with the diode for obtaining maxi	mum current				
	(a) $1.5 \Omega$					
	(b) 5 Ω					
	(c) $6.67 \Omega$					
	(d) 200 Ω					
	$-1$ $P$ $100 \times 10^{-3}$	1.5 V				
<i>Solution</i> : (b)	The current through circuit $i = \frac{P}{V} = \frac{100 \times 10^{-3}}{0.5} = 0.2$	A				
	$\therefore$ voltage drop across resistance = 1.5 – 0.5 = 1 $V\Rightarrow$	$R = \frac{1}{0.2} = 5 \Omega$				
Example: 10	For a transistor amplifier in common emitter configu	0.2				
Lample, 10	$h_{oe} = 25$ ) the current gain is	and on tor four imponence of 1 ks2 (fige – 50 and				
	(a) $-5.2$ (b) $-15.7$	(c) $-24.8$ (d) $-48.78$				

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Solution $\cdot$ (d)	In common emitter configuration current gain	$A = \frac{-h_{fe}}{-h_{fe}}$	$= \frac{-50}{-50} = -48.78$
botutton (a)	In common emitter configuration current gain	$1 + h_{oe} R_L$	$1 + 25 \times 10^{-6} \times 10^{3}$

**Example:** 11 In the following common emitter configuration an *NPN* transistor with current gain  $\beta$  = 100 is used. The output voltage of the amplifier will be [AIIMS 2003]

10KO

1mV

Vour - Vin A Vortage gam

 $V_{out}$ 

(a) 10 mV (b) 0.1 V (c) 1.0 V

(d) 10 V

Output voltage Voltage gain =Solution : (c) Input voltage

> $\Rightarrow V_{out} = V_{in} \times \text{Current gain} \times \text{Resistance gain} = V_{in} \times \beta \times \frac{R_L}{R_{BE}} = 10^{-3} \times 100 \times \frac{10}{1} = 1V.$ While a collector to emitter voltage is constant in a transistor, the collector current changes by 8.2

Example: 12 mA when the emitter current changes by 8.3 mA. The value of forward current ratio  $h_{fe}$  is (a) 82 (b) 83 (c) 8.2 (d) 8.3  $(\Lambda i)$ 8 2 82

Solution : (a) 
$$h_{fe} = \left(\frac{\Delta t_c}{\Delta i_b}\right)_{V_{ee}} = \frac{8.2}{8.3 - 8.2} =$$

The transfer ratio of a transistor is 50. The input resistance of the transistor when used in the **Example: 13** common-emitter configuration is 1  $K\Omega$ . The peak value for an ac input voltage of 0.01 V peak is (c) 0.25 *mA* (d) 500 µA (a) 100 µA (b) 0.01 *mA* - -0.01 A

Solution: (d) 
$$i_c = \beta i_b = \beta \times \frac{V_i}{R_i} = 50 \times \frac{0.01}{1000} = 500 \times 10^{-6} A = 500 \mu$$

In a common base amplifier circuit, calculate the change in base current if that in the emitter current **Example: 14** is 2 *mA* and  $\alpha$  = 0.98 [BHU 1995] (c) 0.98 mA (a) 0.04 *mA* (b) 1.96 mA (d) 2 *mA*  $\Delta i_c = \alpha \, \Delta i_e = 0.98 \times 2 = 196 \, mA$ Solution : (a)

 $\therefore \quad \Delta i_b = \Delta i_e - \Delta i_c = 2 - 1.96 = 0.04 \, mA \, .$